## Abstract Submitted for the MAR14 Meeting of The American Physical Society

## Interface

engineered resistive switching in Ag/SrTiO<sub>3</sub>/Nd<sub>0.7</sub>Ca<sub>0.3</sub>MnO<sub>3</sub>/YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub> devices ZHONGWEN XING, Nanjing University, GRACE LIN, National Taiwan University — Effects of buffer layer of  $SrTiO_3$  (STO) on the room temperature resistive switching devices of Ag/Nd<sub>0.7</sub>Ca<sub>0.3</sub>MnO<sub>3</sub>/YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub> (Ag/NCMO/YBCO) are investigated for the first time. It is found that the insertion of the STO buffer layer into the interface between Ag and NCMO greatly increases the electric-fieldinduced-resistance (EPIR) ratio. The device can be switched on-and-off from a higher to lower resistance state with a ratio of 253% (405%) at the pulsed voltage of  $\pm$  1.5 volt ( $\pm$  3.0 volt). The enhancement of EPIR ratio is attributed to the modification of the Ag/NCMO interface and the electric-pulse driven oxygen vacancy.

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